

Special Issue

Metal Oxides and Their Composites for Photocatalytic Degradation

Message from the Guest Editors

This Special Issue will focus on the recent developments in metal oxides and their composite photocatalysts for wastewater treatment, as well as their reaction mechanisms. Submissions in the form of both original research articles and reviews are welcome on topics encompassing the design of novel materials and the development of new synthetic routes for applications in photocatalytic pollutant degradation.

Guest Editors

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Editor-in-Chief

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